

# GaAs HEMT MMIC 1 WATT POWER AMPLIFIER, 22.5 - 26.5 GHz

## Typical Applications

This HMC-APH608 is ideal for:

- Point-to-Point Radios
- · Point-to-Multi-Point Radios
- VSAT
- Military & Space

#### **Features**

Output IP3: +40 dBm

P1dB: +30 dBm

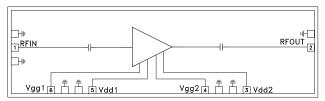
Gain: 17 dB

Supply Voltage: +5V

50 Ohm Matched Input/Output

Die Size: 4.49 x 1.31 x 0.1 mm

## **Functional Diagram**



## **General Description**

The HMC-APH608 is a high dynamic range, two stage GaAs HEMT MMIC 1 Watt Power Amplifier which operates between 22.5 and 26.5 GHz. The HMC-APH608 provides 17 dB of gain, and an output power of +30 dBm at 1 dB compression from a +5V supply voltage. All bond pads and the die backside are Ti/Au metallized and the amplifier device is fully passivated for reliable operation. The HMC-APH608 GaAs HEMT MMIC 1 Watt Power Amplifier is compatible with conventional die attach methods, as well as thermocompression and thermosonic wire bonding, making it ideal for MCM and hybrid microcircuit applications. All data Shown herein is measured with the chip in a 50 Ohm environment and contacted with RF probes.

## Electrical Specifications<sup>[1]</sup>, $T_A = +25^{\circ}$ C, Vdd1=Vdd2 = 5V, Idd1+Idd2 = 950 mA <sup>[2]</sup>

Parameter	Min.	Тур.	Max.	Min.	Тур.	Max.	Units
Frequency Range		22.5 - 26.5			24 - 26.5		GHz
Gain	14.5	17		16	17		dB
Input Return Loss		8			11		dB
Output Return Loss		9			12		dB
Output power for 1dB Compression (P1dB)	27	30		28	30		dBm
Output Third Order Intercept (IP3)	36	39		37	40		dBm
Supply Current (Idd1+Idd2)		950			950		mA

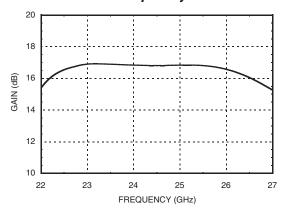
 $<sup>\[1\]</sup>$  Unless otherwise indicated, all measurements are from probed die

<sup>[2]</sup> Adjust Vgg1=Vgg2 between -1V to +0.3V (typ. -0.5V) to achieve Idd1 = 350 mA, Idd2 = 600 mA

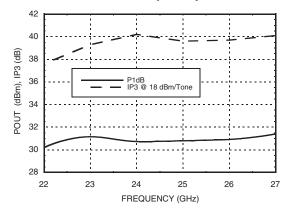


# GaAs HEMT MMIC 1 WATT POWER AMPLIFIER, 22.5 - 26.5 GHz

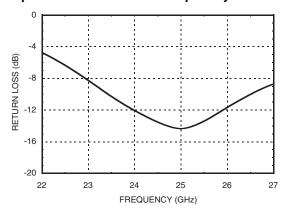
### Linear Gain vs. Frequency



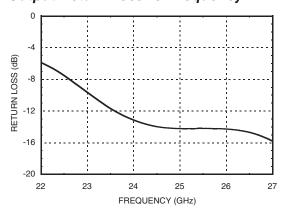
#### Fixtured Pout vs. Frequency



### Input Return Loss vs. Frequency



## **Output Return Loss vs. Frequency**





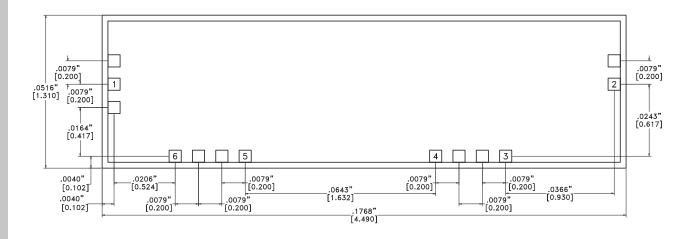
## GaAs HEMT MMIC 1 WATT POWER AMPLIFIER, 22.5 - 26.5 GHz

## **Absolute Maximum Ratings**

Drain Bias Voltage	+5.5 Vdc	
Gate Bias Voltage	-1 to +0.3 Vdc	
Thermal Resistance (Channel to die bottom)	23.9 °C/W	
Channel Temperature	180 °C	
Storage Temperature	-65 °C to +150 °C	
Operating Temperature	-55 °C to +85 °C	



## **Outline Drawing**



## Die Packaging Information [1]

Standard	Alternate	
GP-2 (Gel Pack)	[2]	

[1] Refer to the "Packaging Information" section for die packaging dimensions.

[2] For alternate packaging information contact Hittite Microwave Corporation.

#### NOTES:

- 1. ALL DIMENSIONS ARE IN INCHES [MM].
- 2. TYPICAL BOND PAD IS .004" SQUARE.
- 3. BACKSIDE METALLIZATION: GOLD.
- 4. BACKSIDE METAL IS GROUND.
- 5. BOND PAD METALLIZATION: GOLD.
- ${\bf 6.}\ \ {\bf CONNECTION}\ {\bf NOT}\ {\bf REQUIRED}\ {\bf FOR}\ {\bf UNLABELED}\ {\bf BOND}\ {\bf PADS}.$
- 7. OVERALL DIE SIZE ±.002"



## GaAs HEMT MMIC 1 WATT POWER AMPLIFIER, 22.5 - 26.5 GHz

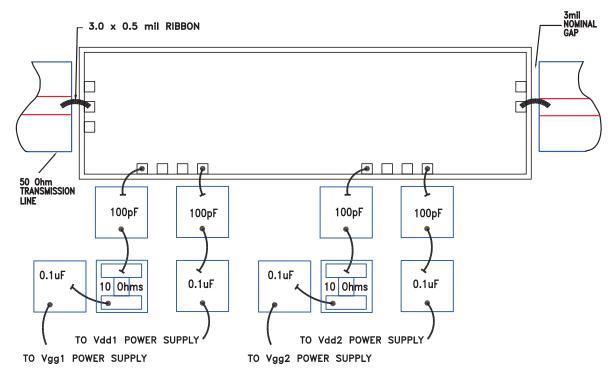
## **Pad Descriptions**

Pad Number	Function	Description	Interface Schematic
1	RFIN	This pad is AC coupled and matched to 50 Ohms.	RFIN ○──
2	RFOUT	This pad is AC coupled and matched to 50 Ohms.	—   —○ RFOUT
3, 5	Vdd1, Vdd2	Power Supply Voltage for the amplifier. See assembly for required external components.	Vdd1,0 Vgg2
4, 6	Vgg1, Vgg2	Gate control for the amplifier. Please follow "MMIC Amplifier Biasing Procedure" application note. See assembly for required external components.	Vgg1, Vgg2 T T T
Die Bottom	GND	Die bottom must be connected to RF/DC ground.	GND =



## GaAs HEMT MMIC 1 WATT POWER AMPLIFIER, 22.5 - 26.5 GHz

## **Assembly Diagram**



Note 1: Bypass caps should be 100 pF (approximately) ceramic (single-layer) placed no farther than 30 mils from the amplifier

Note 2: Best performance obtained from use of <10 mil (long) by 3 by 0.5mil ribbons on input and output.



# GaAs HEMT MMIC 1 WATT POWER AMPLIFIER, 22.5 - 26.5 GHz

### Mounting & Bonding Techniques for Millimeterwave GaAs MMICs

The die should be attached directly to the ground plane eutectically or with conductive epoxy (see HMC general Handling, Mounting, Bonding Note).

50 Ohm Microstrip transmission lines on 0.127mm (5 mil) thick alumina thin film substrates are recommended for bringing RF to and from the chip (Figure 1). If 0.254mm (10 mil) thick alumina thin film substrates must be used, the die should be raised 0.150mm (6 mils) so that the surface of the die is coplanar with the surface of the substrate. One way to accomplish this is to attach the 0.102mm (4 mil) thick die to a 0.150mm (6 mil) thick molybdenum heat spreader (moly-tab) which is then attached to the ground plane (Figure 2).

Microstrip substrates should be placed as close to the die as possible in order to minimize bond wire length. Typical die-to-substrate spacing is 0.076mm to 0.152 mm (3 to 6 mils).

# 0.076mm to 0.152 mm (3 to 6 mils). Handling Precautions

Follow these precautions to avoid permanent damage.

**Storage:** All bare die are placed in either Waffle or Gel based ESD protective containers, and then sealed in an ESD protective bag for shipment. Once the sealed ESD protective bag has been opened, all die should be stored in a dry nitrogen environment.

**Cleanliness:** Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.

Static Sensitivity: Follow ESD precautions to protect against ESD strikes.

**Transients:** Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pickup.

**General Handling:** Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip may have fragile air bridges and should not be touched with vacuum collet, tweezers, or fingers.

#### Mounting

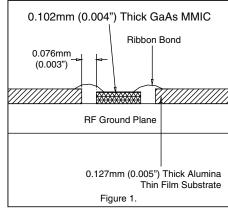
The chip is back-metallized and can be die mounted with AuSn eutectic preforms or with electrically conductive epoxy. The mounting surface should be clean and flat.

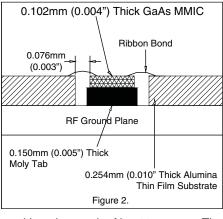
Eutectic Die Attach: A 80/20 gold tin preform is recommended with a work surface temperature of 255 °C and a tool temperature of 265 °C. When hot 90/10 nitrogen/hydrogen gas is applied, tool tip temperature should be 290 °C. DO NOT expose the chip to a temperature greater than 320 °C for more than 20 seconds. No more than 3 seconds of scrubbing should be required for attachment.

Epoxy Die Attach: Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip once it is placed into position. Cure epoxy per the manufacturer's schedule.

#### Wire Bonding

RF bonds made with 0.003" x 0.0005" ribbon are recommended. These bonds should be thermosonically bonded with a force of 40-60 grams. DC bonds of 0.001" (0.025 mm) diameter, thermosonically bonded, are recommended. Ball bonds should be made with a force of 40-50 grams and wedge bonds at 18-22 grams. All bonds should be made with a nominal stage temperature of 150 °C. A minimum amount of ultrasonic energy should be applied to achieve reliable bonds. All bonds should be as short as possible, less than 12 mils (0.31 mm).





# **X-ON Electronics**

Largest Supplier of Electrical and Electronic Components

Click to view similar products for RF Amplifier category:

Click to view products by Analog Devices manufacturer:

Other Similar products are found below:

A82-1 BGA622H6820XTSA1 BGA 728L7 E6327 BGB719N7ESDE6327XTMA1 HMC397-SX HMC405 HMC561-SX HMC8120-SX HMC8121-SX HMC-ALH382-SX HMC-ALH476-SX SE2433T-R SMA3101-TL-E SMA39 A66-1 A66-3 A67-1 A81-2 LX5535LQ LX5540LL MAAM02350 HMC3653LP3BETR HMC549MS8GETR HMC-ALH435-SX SMA101 SMA32 SMA411 SMA531 SST12LP19E-QX6E WPM0510A HMC5929LS6TR HMC5879LS7TR HMC1087F10 HMC1086 HMC1016 SMA1212 MAX2689EWS+T MAAMSS0041TR MAAM37000-A1G LTC6430AIUF-15#PBF SMA70-2 SMA4011 A231 HMC-AUH232 LX5511LQ LX5511LQ-TR HMC7441-SX HMC-ALH310 XD1001-BD-000V A4011